

PROCEEDINGS OF SPIE

Advanced Lasers, High-Power Lasers, and Applications XIV

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Editors

14–16 October 2023
Beijing, China

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Published by
SPIE

Volume 12760

Proceedings of SPIE 0277-786X, V. 12760

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Advanced Lasers, High-Power Lasers, and Applications XIV, edited by Jun Liu,
Shibin Jiang, Ingmar Hartl, Proc. of SPIE Vol. 12760, 1276001
© 2023 SPIE · 0277-786X · doi: 10.1117/12.3019083

Proc. of SPIE Vol. 12760 1276001-1

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Please use the following format to cite material from these proceedings:

Author(s), "Title of Paper," in *Advanced Lasers, High-Power Lasers, and Applications XIV*, edited by Jun Liu, Shibin Jiang, Ingmar Hartl, Proc. of SPIE 12760, Seven-digit Article CID Number (DD/MM/YYYY); (DOI URL).

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510667693
ISBN: 9781510667709 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA

Telephone +1 360 676 3290 (Pacific Time)

SPIE.org

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